Probing Electronic Structure in Novel Engineered Quantum States of Matter

In situ ARPES Studies of Epitaxial Novel Oxides Thin Films

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V. V. Nemoshkalenko Memorial Conference and Workshop ES&ES13 Mingying Li, Haifeng Yang and Zhengtai Liu, and Hongping Mei SIMIT, CAS

- Daniel E. Shai, Carolina Adamo, Charles M. Brooks, John W. Harter, Eric J. Monkman, B. Burganov, Prof. Darrell. G. Schlom, and Prof. Kyle. M. Shen Cornell University
- The set-up of OMBE/ARPES systems at SIMIT and partial work on SrRuO₃ epitaxial thin films
- The design and set-up of OMBE/ARPES systems at Cornell and most work on SrRuO₃ epitaxial thin films

- Rui Peng, Haichao Xu, Miao Xia, Xin Xie, Prof. Binping Xie, and Prof. Donglai Feng Fudan University
- The work on the dead-layer of LSMO/STO interface

The Trend: Discovering and Engineering Novel Quantum Matters

"At the extreme forefront of research in superconductivity is the empirical search for new materials"

Bednorz and Mueller ('86)









Atomic-scale layer-by-layer growth

G. Logvenov et al., Science 326, 699 (2009) A. Gozar et al., Nature 455, 782 (2008)

Rational Materials Design: Desired Correlated-electron properties



BEYOND SILICON? Sixty years ago, semiconductors were a scientific curiosity. Then researchers tried putting one type of semiconductor up against another, and suddenly we had diodes, transistors, microprocessors, and the whole electronic age. Startling results this year may herald a similar burst of discoveries at the interfaces of a different class of materials: transition metal oxides.

Transition metal oxides first made headlines in 1986 with the Nobel Prize-winning discovery of high-temperature superconductors. Since then, solid-state physicists keep finding unexpected properties in these materials—including colossal magnetoresistance, in which small changes in applied magnetic fields cause huge changes in electrical resistance. But the fun should really start when one oxide rubs shoulders with another.

If different oxide crystals are grown in layers with sharp interfaces,

the effect of one crystal structure on another can shift the positions of atoms at the interface, alter the population of electrons, and even change how

Tunable sandwich. In lanthanum aluminate sandwiched between layers of strontium titanate, a thick middle layer (*right*) produces conduction at the lower interface; a thin one does not.



The Cover of Science, Vol . 318 (2007)

Rational Materials Design: How can we control the properties of matter emerging from complex correlations by design?



Ohtomo, Muller, Grazul, Hwang, Nature, 419; DOE BESAC Report (2008) Great Success of Band-gap engineering in conventional semiconductors







Quantum confinement effects

Strain band gap engineering

Correlated Transition Metal Oxides



Th Pa U Np Pu Am Cm Bk Cf Es Fm Md No Lr

$$\mathcal{H} = \begin{bmatrix} -\sum_{j}^{N_{e}} \frac{\hbar^{2}}{2m} \nabla_{j}^{2} \\ -\sum_{\alpha}^{N_{i}} \frac{\hbar^{2}}{2M_{\alpha}} \nabla_{\alpha}^{2} - \sum_{j}^{N_{e}} \sum_{\alpha}^{N_{i}} \frac{Z_{\alpha}e^{2}}{|\vec{r_{j}} - \vec{R}_{\alpha}|} + \begin{bmatrix} \sum_{j \ll k}^{N_{e}} \frac{e^{2}}{|\vec{r_{j}} - \vec{r_{k}}|} \\ \frac{e^{-} \text{KE}}{|\vec{R}_{\alpha} - \vec{R}_{\beta}|} \end{bmatrix}$$

$$e^{-} \text{KE} \qquad \text{Nuclei KE} \qquad e^{-} / \text{Nuclei Int.} \qquad e^{-} / e^{-} \text{Int.} \qquad \text{Nuclei / Nuclei Int.}$$

Non-Interacting



We understand well:

- Systems of non-interacting or weakly interacting particles;
- Interaction energy is smaller than the kinetic energy, perturbation theory works well.
- DFT do nice predictions.

Correlated

- Calculation of physical properties
- Construction of desired materials
- Characterization of microscopic interactions by high-resolution experiments

Control of properties through epitaxial strain & chemical doping

- 1. New tools for investigating novel quantum electronic states
- 2. Correlation in epitaxial Ruthenate Thin Films
- 3. Dead-layer at the $La_{1-x}Sr_{x}MnO_{3}/SrTiO_{3}$ interface



Oxide Molecular Beam Epitaxy



Angle-Resolved Photoemission Spectroscopy

Oxide Molecular Beam Epitaxy : "Atomic Spray Painting"

<u>Shuttered growth</u> utilizes alternating molecular beams so that each element is evaporated separately.



Characterization by Angle-Resolved Photoemission Spectroscopy



From momentum/energy conservation rules:

$$k_{pe} = -k_{N-1}$$

$$hv - E_{pe} = E_{N-1} - E_N$$

Direct Mapping of "Band" E Sr₂RhO₄



Courtesy of Prof. Donglai Feng

http://arpes.stanford.edu/research_strontium_ruthnates.html

The necessity and possibility of synergistic collaborations

Limitations of ARPES

Highly surface sensitive (atomically clean surfaces)

Mostly restricted to cleavable samples (need well-defined layer-structured crystals)

Requires sizable single crystals

~ mm-sized

Advantages of OMBE

Films grown under ultrahigh vacuum conditions, not energetic deposition

Epitaxial growth allows for study of "uncleavable" materials

Allow for growth of "artificial" materials : heterostructures, interfaces, epitaxially strained materials

Integrated Oxide MBE + ARPES at SIMIT



The mode of rational materials design for complex quantum matters



J. M. Rondinelli and S. J. May, Nature materials, 11, 833 (2012)

Preliminary reliability testing of the integrated OMBE/ARPES



Outline

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Sr-based Ruthenates SrO(SrRuO₃)_n : Rich physics



http://www.phys.psu.edu/~liu/

Characterization of SrRuO₃ Epitaxial films



- The fringes indicate good crystalline quality of the films
- Right 20 value of the (002) peak for stained SrRuO₃ films

Transport measurements

Residual resistivity ratio RRR ~27.4, the record high quality of $SrRuO_3$ thin film



So far the best SrRuO₃ thin films (~20nm) reported

What does the electronic structure look like?



Siemons et al., PRB 76, 075126(2007)

Photoemission spectra are sensitive to the stoichiometry

The first probe of the k dependent electronic structure



Helα (21.2eV)

Hell (40.8eV)

 k_F 's are consistent with both DFT prediction and previous bulk sensitive quantum oscillation measurements on SrRuO₃.

A. P. Mackenzie et al., PRB (1998) and C. S. Alexander et al., PRB (2005)

What is the origin of the strong correlation?



- Evident 'kink' at ~65meV: signature of a strong coupling to some bosonic modes:
 - Low binding energy: heavily dressed QP (M*= 4.5 M_{LDA}), in good agreement with dH-vA oscillations;
 - High binding energy: similar slope as DFT, weak e-e correlation.
- Naturally explain the long-standing puzzle about the strong correlation effects.

What is the origin of the ferromagnetism in SrRuO₃?



- The Stoner model: the exchange splitting of an itinerant FM should decrease from its saturation value at low temperatures to zero at Tc.
- > A strong deviation of the band dispersion from the Stoner model.
- The magnetism has a strong local character and cannot be explained in a simple picture of itinerant Stoner FM.

For the first time, high resolution ARPES is conducted on epitaxial SrRuO₃ thin films to extract the electronic structure:

- High accuracy Fermi surface maps, in agreement with DFT calculation;
- Strong kink structure in QPs' dispersion

□ Many-body interactions in SrRuO₃ thin films are anatomized:

- Strong coupling to some bosonic modes, e-ph? Magnons?
- Relatively weak e-e correlations.
- The magnetism has a strong local character.

<u>Naturally explain the long-standing puzzle</u> <u>about the strong correlation effects.</u>

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Dead-layer phenomenon at La_{0.67}Sr_{0.33}MnO₃/SrTiO₃ interfaces



7 unit cells on LSMO/STO

Dead layer—strongly affected by defects

Oxide MBE:

Sharp interface, low energy

Iow defect densities

Nakagawa, Nature materials (2006) Tebano et al., PRL 100, 137401 (2008) Kim et al., Solid State Communications 150(13–14): 598-601 H. Boschker et al., AdFuncMat 22,2235 (2012)

Possible mechanisms:Charge redistribution





Strain effect



Magnetic and orbital reconstruction



Fine scan around (002)





FWHM=0.015, limited by the substrate



Absolute thickness error within 2%

Cross-sectional TEM image



Confirm the 7uc thickness

Transport properties v.s. thickness



➢ 32 u.c. ~ bulk;

- Both of Curie temperature and conductivity drop upon decreasing thickness;
- > Below 7u.c., the films are insulating below Tc, as a typical dead-layer behavior.

Remarkable similarity in the phase diagram to the doped bulk



In bulk: double-exchange is suppressed \rightarrow metal-insulator transition



The same mechanism for ultrathin films?

Moreo, A., et al., Science 283, 2034 (1999).

Oxygen vacancies \rightarrow hole concentration and bond angle change





- The Mn-O hybridized band, shifts towards higher binding energy with decreasing thickness.
- Similar shift is observed in the 30 u.c. film intentionally grown under oxygen deficient condition
- > This valence band shift closely related to the oxygen deficiency

Picozzi, S., et al., Phys. Rev. B. 75, 094418 (2007). Schlueter, C., et al. Phys. Rev. B. 86, 155102 (2012).

Other evidence from LEED





substate



6 u.c. 15 u.c. well oxidized well oxidized



30 u.c.

30 u.c. well oxidized oxygen deficient

- Both the ultra-thin films and the intentionally oxygen deficient thick film show an additional surface reconstruction.
- Further annealing in ozone did not cause any variation in the valence band or LEED patterns of the ultra-thin films.

Intrinsic oxygen vacancy formation appear in ultra-thin films ----- change the carrier concentration, and suppress the double exchange

Interface engineering based on this model





The deteriorated metallicity and ferromagnetism with decreased thickness can be compensated by higher interfacial Sr doping.

The dead-layer is successfully reduced to 6 u.c.

- ARPES is a powerful tool to study the strongly interacting solid state materials; BUT, it is greatly limited to the cleavable samples.
- MBE+ARPES technique can greatly extend our research scope to originally unachievable materials phase;
- It also provides a great tool to customize and characterize the oxide thin films with desired functions.



Thanks for your attention!